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## Redesign Processes in the Age of the Fourth Industrial Revolution

Guest Editor:

#### Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

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# **Message from the Guest Editor**

Dear Colleagues,

This Special Issue, which is supported by the journal's Editorial Board, aims to highlight new comprehensive transdisciplinary models for the design of innovative processes in a range of Science and Technology fields. This holistic approach is reshaping current research and production strategies, which are too often confined to traditional, linear thought patterns. The merging of academic and industrial experience with economic and environmental knowledge will help laboratories, industries, and businesses achieve sustainable growth. We are expecting papers with the power to disrupt and innovate, which exploit combinations of technologies to shape our future processes.

Prof. Dr. Giancarlo Cravotto Guest Editor











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## **Editor-in-Chief**

### Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

## Message from the Editor-in-Chief

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